

Rigorous component testing, although necessary, is not sufficient. Software components can be combined, but their combination could be wrong even though the components test well individually. A combination that is insensitive to minor component errors could still give invalid results. Each component has an unstated region of applicability that is often horribly complicated to describe, yet the combination could unexpectedly exceed individual component limits.

Josip Loncaric

(jl-icase@comcast.net)
Los Alamos, New Mexico

Douglass Post and Lawrence Votta's article admirably stresses the need for validation of computation. If I understand their main point correctly, it's that computation is science, not mathematics.

The article motivates me to contrast two fields I work between that use very different paradigms to describe the electrodiffusion of charge. In computational electronics,^{1,2} the electric field is traditionally calculated by solving Poisson's equation with far-field boundary conditions but at relatively low resolution. Poisson is solved anew whenever charges move. Com-

putational chemistry, starting more or less with computer simulation of fluids³ and computational biology,⁴ computes the electric field at high resolution and does not deal clearly with far-field boundary conditions.

Electrodiffusion, which has been at the center of electro- and physical chemistry since Michael Faraday's time, is also at the center of electronics, where it describes the movement of charge in semiconductors and most of our digital devices. Electrodiffusion is no less important in biophysics, where it is responsible for the electrical properties of cells and tissues, and controls many biological functions.

It seems to me that these different treatments of similar physics are distinct and unlikely to be equally precise under all conditions. I hope the article helps motivate workers in each tradition to discuss other treatments beyond their own and try to understand the differences. I hope such workers can determine the conditions under which each treatment is accurate. That way we may learn to use each computational tradition of electrodiffusion only in appropriate situations.

References

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Bob Eisenberg

(beisenbe@rush.edu)

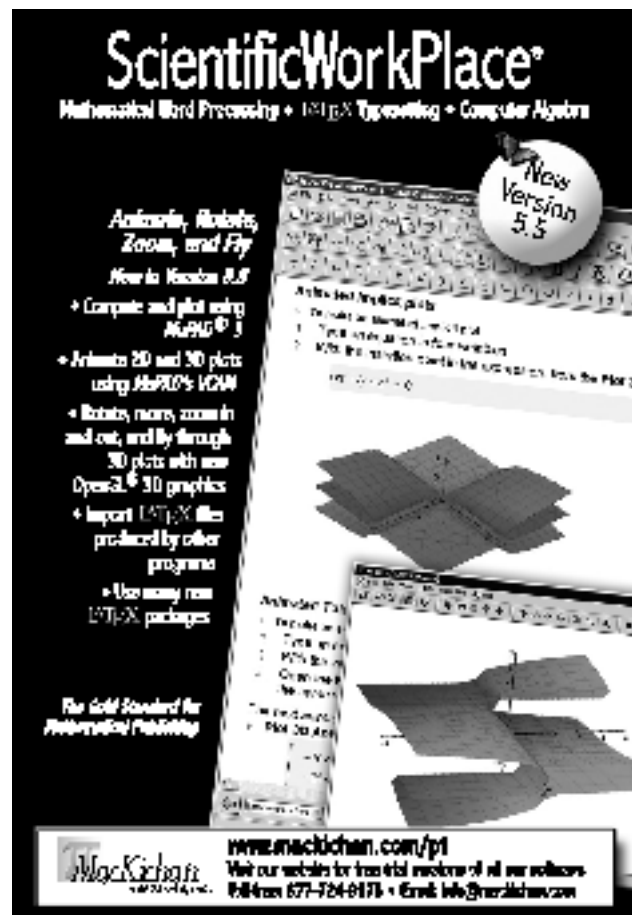
Rush University Medical Center
Chicago, Illinois

Post and Votta correctly point out the need for validation of software programs. Validation is often thought to mean the absolute prediction of measurements. However, new software often replicates measurement trends accurately long before predicting absolute values well. When time is critical, trends are frequently sufficient to guide new designs or predict outcomes. Sometimes the technology is no longer relevant once the model software finally replicates absolute measurements.

R. Casanova Alig

(alig@mailaps.org)

Princeton Junction, New Jersey



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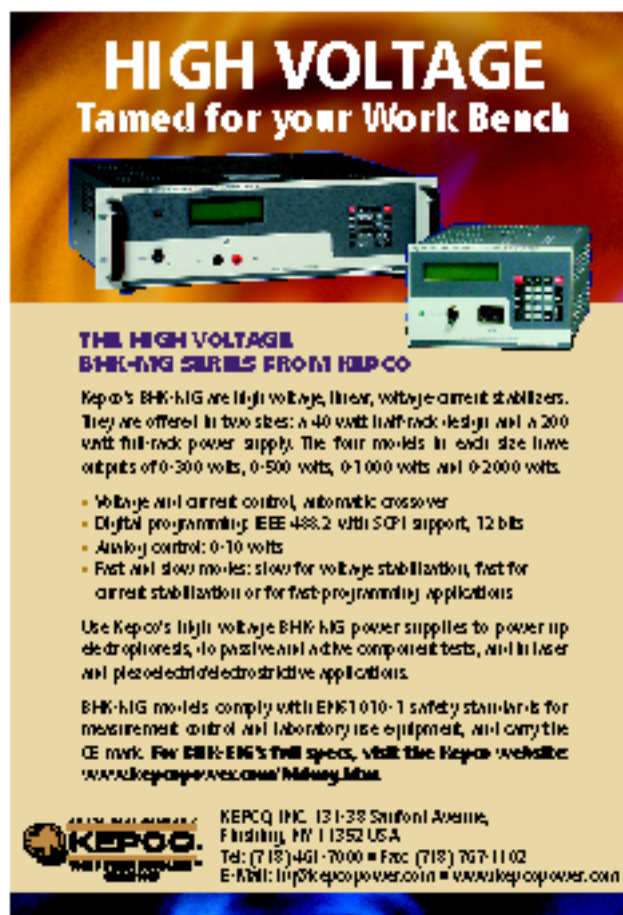
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